## **Supporting Information**

A crosslinked fullerene matrix doped with an ionic fullerene as a cathodic buffer layer toward highperformance and thermally stable polymer and organic metallohalide perovskite solar cells

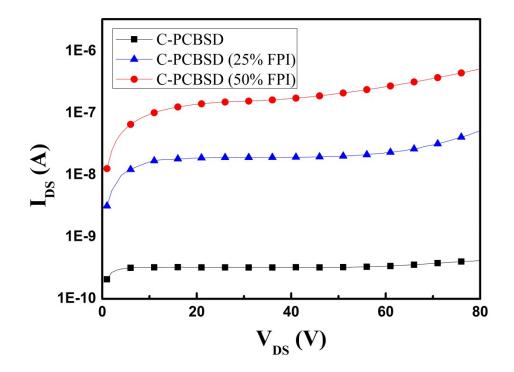
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**Figure S1.** N-type OFET electrical characteristic of C-PCBSD films at varied dopant concentration

**Table S1.**Summary of OFET device performance of C-PCBSD with varying FPI

Material	Electron mobility (cm <sup>2</sup> V <sup>-1</sup> s <sup>-1</sup> )
C-PCBSD	$1.3  imes 10^{-5}$
C-PCBSD (FPI, 25%)	$2.4  imes 10^{-5}$
C-PCBSD (FPI, 50%)	$6.0  imes 10^{-5}$

dopant concentration